

A BENT CYCLOPOLYSILANE ANION-RADICAL ($\underline{i}\text{-Pr}_2\text{Si}$)₄

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The ESR spectra for ($\underline{i}\text{-Pr}_2\text{Si}$)₄^{•-} and ($\underline{s}\text{-Bu}_2\text{Si}$)₄^{•-} show two equally-intense splitting constants for $\alpha\text{-}^{13}\text{C}$, indicating that these anion-radicals are bent and not rapidly interconverting.

Cyclopolysilanes undergo reduction to anion-radicals in which the unpaired electron is delocalized over the ring.¹⁾ Numerous anion-radicals of four-, five-, and six-membered ring cyclopolysilanes have been investigated by ESR spectroscopy in recent years.²⁻⁸⁾ When these rings are of the form (R_2Si)_n^{•-} (with all substituents R identical), in general they show only single values for the $\alpha\text{-}^{13}\text{C}$ hyperfine splitting constant (hfsc), as well as for the $\alpha\text{-}^1\text{H}$ hfsc when it is large enough to be observed. These findings imply that such anion-radicals (R_2Si)_n^{•-}, n = 4 to 6, are either planar or rapidly interconverting on the ESR time scale.

An exception to this generalization has now been observed, for octakis-(\underline{i} -propyl)cyclotetrasilane, 1.⁹⁾ The ESR spectrum for the anion-radical of 1 in THF at -90 °C is shown in Fig. 1. Two equally-intense $\alpha\text{-}^{13}\text{C}$ sidebands are observed, with hfsc 18.58 and 14.40 G. Integration of the bands shows that each has an intensity corresponding to four carbon atoms. The spectrum indicates that anion-radical ($\underline{i}\text{-Pr}_2\text{Si}$)₄^{•-} is nonplanar, and that interconversion between equivalent nonplanar forms is slow compared to the ESR spin relaxation time. This interpretation is strengthened by the recent finding that the parent cyclosilane 1 also exists in a folded, nonplanar conformation,¹⁰⁾ with a ring bending angle of 37.1°.

The anion-radical of octakis(\underline{s} -butyl)cyclotetrasilane, 2,⁹⁾ also shows

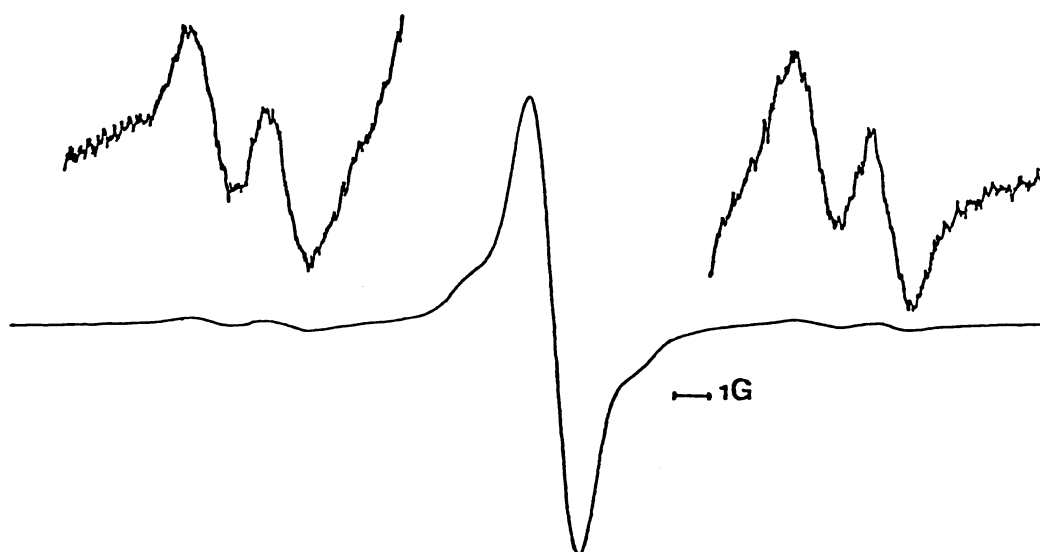


Fig. 1. ESR spectrum of $(i\text{-Pr}_2\text{Si})_4^{\bullet-}$, electrochemically reduced, in THF at -90°C . The inset spectra, determined at higher gain, show the equally-intense $\alpha\text{-}^{13}\text{C}$ sidebands.

two equally-intense $\alpha\text{-}^{13}\text{C}$ hfsc, Table 1. We interpret this finding as due to similar nonplanarity of the anion-radical; the structure of neutral **2** is as yet unknown but we predict that it will also be nonplanar. The ESR spectra of both compounds were temperature-independent over the range from -90 to -50°C .

From these results it appears that the dichotomy between planar and nonplanar cyclotetrasilanes, recently discovered for neutral compounds, applies also to anion-radicals. The information available to date is listed in Table 1.

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Table 1. Structures of Symmetrical Cyclotetrasilanes, as Neutral Molecules and Anion-Radicals

Neutral molecule				Anion-radical		
R in $(R_2Si)_4$	Structure	Dihedral angle/deg	Ref.	$\alpha\text{-}^{13}C, G$	Structure	Ref.
Me	planar	0	11	20.97	p-r ^{a)}	7
Et				18.40	p-r ^{a)}	7
Me ₃ Si	planar	0	12			
Ph	bent		13	13.1	p-r ^{a)}	3,8
<u>i</u> -Pr	bent	37.1	10	18.58, 14.40	bent	this work
<u>s</u> -Bu				18.36, 14.42	bent	this work
Me ₃ SiCH ₂	bent	38.8	10,14			
Me ₃ CCH ₂	bent	38.8	15			

a) Either planar or rapidly interconverting.

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